

# Thin Film Deposition

Drawing on years of experience in depositing semiconductor-quality oxides, nitrides, chalcogenides, and metals, we offer a fast path to high-quality films.

SERVICE	METHOD	TECHNOLOGY	FOCUS AREA
Thin Film Deposition	PVD	R&D	Single layer, multi-layers, & co-sputtering on multi-chamber cluster tool with 300mm wafer capability
		Pilot/HVM	Single layer, & multi-layers, on 200mm HVM multi-chamber cluster tool
			Single layer, & multi-layers, on 300mm HVM tool
	ALD	R&D	Single layer, multi-layers, and combinatorial ALD on multi-chamber cluster tool with 300mm wafer capability
	PE-ALD		
	CVD		Single layer, multi-layers, and combinatorial CVD on multi-chamber cluster tool with 300mm wafer capability
	PECVD		Single layer, multi-layers, and combinatorial PECVD on multi-chamber cluster tool with 300mm wafer capability